



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 1862
Taku HIRAYAMA et al. : Attorney Docket No. 2005_0892A
Serial No. 10/537,290 : Group Art Unit 1752
Filed June 1, 2005 : Examiner Sin J. Lee
CHEMICAL-AMPLIFICATION TYPE : Mail Stop: AMENDMENT
SILICONE-BASED POSITIVE-WORKING
PHOTORESIST COMPOSITION

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO 23-0975

Sir:

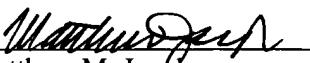
Petition hereby is made for a one month extension of time to respond to the communication of October 3, 2007.

The fee of \$120.00 is

(X) submitted herewith.
(to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.
(Small entity status of this application is established by a Small Entity Status Assertion which
(is enclosed.
(has been previously submitted.
(has been previously asserted.

Respectfully submitted,

Taku HIRAYAMA et al.

By: 
Matthew M. Jacob
Registration No.25,154
Attorney for Applicants

MJ/aas
Washington, D.C. 20006-1021
Telephone (202) 721-8200
Facsimile (202) 721-8250
January 29, 2008

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